



WORLD INTELLECTUAL PROPERTY ORGANIZATION

34, chemin des Colombettes, P.O. Box 18, CH-1211 Geneva 20 (Switzerland)
 ‡ (41-22) 338 91 11 – Facsimile (International Trademark Registrations Section): (41-22) 740 14 29
 e-mail: intreg.mail@wipo.int – Internet: <http://www.wipo.int>

PROTOCOL RELATING TO THE MADRID AGREEMENT CONCERNING THE INTERNATIONAL REGISTRATION OF MARKS

Individual Fees under Article 8(7): Benelux

1. The Benelux Trademark Office has sent a notification to the International Bureau, the effect of which is to change the amount of the individual fee payable under Article 8(7) of the Madrid Protocol when Benelux is designated under the Protocol either in an international application or in a designation subsequent to international registration, or in respect of renewal of an international registration in which Benelux has been designated.

2. In accordance with Rule 35(2)(b) of the Common Regulations under the Madrid Agreement and Protocol, the Director General has, after consultation with the said Office, established the following new amounts, in Swiss francs, of the said individual fee:

Designation fee (in the international application or in a subsequent designation):	CHF
– for three classes of goods or services	201
<i>where the mark is collective mark</i>	286
– for each additional class	19
Renewal fee:	CHF
– for three classes of goods or services	329
<i>where the mark is a collective mark</i>	599
– for each additional class	59

3. This change will take effect on January 24, 2003. Therefore, these amounts will be payable where Benelux

(a) is designated in an international application which is received, or is deemed to have been received under Rule 11(1)(c), by the Office of origin on or after that date, or

(b) is the subject of a subsequent designation which is received by the Office of origin or another interested Office on or after that date, or is filed direct with the International Bureau on or after that date, or

(c) has been designated in an international registration which is renewed on or after that date.